Form P	TO-144	9 (modified)			Atty. Docket No.		Serial No.	
				2096.001300/5	2096.001300/Serie: 6184 10/622,015			
List of P	atents an	d Publications fo	or Applicant's	Applicant	Applicant Cowles and Bollinger			
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(Other A	Art (Includi	ing Autho	r, Title, Date	Pertin	ent Pag	jes, Etc.)	
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MW	Cl	Chen et al., "Spectrophotometric Determination of Trace and Ultratrace Levels of Boron in Silicon and Chlorosilane Samples," Fresenius J. Anal. Chem., 340:357-362, 1991.						
MW	C2	Cowles and Bollinger, "Point-of-Use Sampling and Metal Analysis for Trichlorosilane," SEMI Technical Symposium (STS): Innovations in Semiconductor Manufacturing, July 2002.						
MW	C3	Stolyarova and Orlova, "Trichlorosilane and Silicon Tetrachloride Sample Preparation for Trace Boron, Phosphorus, and Arsenic Determination," J. Anal. Chem., 50(2):130-134, 1995.						
MW	C4	Wei and Yang, "Determination of Phosphorus and Arsenic in Trichlorosilane by Electrothermal Vaporization-Inductively Coupled Plasma Mass Spectrometry with Prior Concentration by Cuprous Chloride," Fresenius J. Anal. Chem., 353:167-170, 1995.						
MW	C5	Presentation of POU Sampling and Metal Analysis of Trichlorosilane at SEMI Semiconductor Equipment and Materials International, July 2002.						

Examiner: Date Considered: /Maureen Wallenhorst/ (11/29/2006)

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